The Preparation of Cyclic Siliconmethylene Compounds

WILLIAM A. KRINER¹

The Rohm and Haas Company, Philadelphia, Pennsylvania

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A novel method has been found for the preparation of cyclic siliconmethylene compounds such as $[(CH_3)_2-SiCH_2]_2$, $[(CH_3)_2SiCH_2]_3$, $[Cl(CH_3)SiCH_2]_2$, $[C_2H_6O(CH_3)SiCH_2]_2$, $[C_2H_6O(CH_3)SiCH_2]_3$, and others. The above cyclic compounds containing Cl⁻ or $C_2H_5O^-$ groups bonded to silicon were converted to various derivatives such as $[H(CH_3)SiCH_2]_2$, $[H(CH_3)SiCH_2]_3$, $[C_6H_6(CH_3)SiCH_2]_2$, $[C_6H_6(CH_3)SiCH_2]_3$, etc.

The common method for preparing compounds containing the Si–C–Si linkage utilizes the coupling reaction of halomethylsilanes with halo or alkoxy silanes by means of lithium, sodium, or magnesium. These reactions have been reviewed elsewhere.² Cyclic siliconmethylene compounds of the general formula $[(CH_3)_2SiCH_2]_n$ have been prepared in this manner, but in small yields.² A six-membered ring compound, $[Cl_2SiCH_2]_3$, has been isolated from the products of the reaction of CH_2Cl_2 with Si–Cu alloys. This has been converted to $[H_2 SiCH_2]_3$ by reaction with lithium aluminum hydride, and to various alkyl derivatives.² Fritz and co-workers have shown that cyclic siliconmethylenes can be obtained in small quantities from the pyrolysis of $(CH_3)_4$ -Si, $(CH_3)_3SiCl$, $(CH_3)_2SiCl_2$, and $(CH_3)SiCl_3$.²

The smallest cyclic siliconmethylene ring, 1,3-disilacyclobutane, has been synthesized as the 1,1,3,3tetramethyl derivative³ by a multistep process culminating in the ring closure dehalogenation reaction as shown by the following equation.

$$F(CH_3)_2SiCH_2Si(CH_3)_2CH_2Cl + Mg \longrightarrow [(CH_3)_2SiCH_2]_2 + MgCl(F)$$
(1)

A similar preparation was carried out using $Cl(CH_3)_2$ -SiCH₂Si(CH₃)₂CH₂Cl in the final step.⁴ Recently, 1,1,3,3-tetramethyl-1,3-disilacyclobutane was identified as one of the products from the pyrolysis of $(CH_3)_4$ Si.⁵ The four-membered ring compound has also been isolated from the products of the reaction of chloromethyldimethylchlorosilane and magnesium in ether in yields around 4%.⁶

None of the above described methods provides a quick, versatile means for preparing cyclic siliconmethylene compounds in substantial yields. The purpose of this investigation was to perfect a method for preparing these compounds and particularly to introduce some silicon functionality into the rings. The method chosen was similar to that of Müller, *et al.*⁶

Results and Discussion

Direct Preparation of Cyclic Siliconmethylenes.— The interaction of chloromethyldimethylchlorosilane with magnesium in diethyl ether proceeded as in eq. 2. The yield of small ring compounds (n = 2, 3, and 4) was small, in agreement with Müller, *et al.*,⁶ most of the

(1958); W. H. Knoth, Jr., U. S. Patent 2,850,514 (1958).
(4) G. Greber and G. Degler, *Makromol. Chem.*, **52**, 174 (1962).

$$n\text{ClCH}_{2}\text{Si}(\text{CH}_{3})_{2}\text{Cl} + n\text{Mg} \longrightarrow [(\text{CH}_{3})_{2}\text{Si}(\text{CH}_{2}]_{n} + n\text{MgCl}_{2}$$
 (2)
 $n = 2 \text{ and greater}$

product being a viscous residue. The reaction proceeded more readily in tetrahydrofuran; however, the yield of simple compounds was again small, the major product being a siliconmethylene polymer having an average molecular weight of 930 ± 10 . A most successful procedure, resulting in yields up to 50% for 1,1,3,3-tetramethyl-1,3-disilacyclobutane (I) and around 19% for 1,1,3,3,5,5-hexamethyl-1,3,5-trisilacyclohexane (II) and 1,1,3,3,5,5,7,7-octamethyl-1,3,5,7-tetrasilacyclooctane (III) in small quantities, was perfected by utilizing the reverse addition of magnesium to the silane in tetrahydrofuran (reaction 1D in Experimental). High molecular weight cyclic silmethylenes and possibly some linear compounds probably linked with Si-O-Si bonds, due to hydrolysis of residual Si-Cl end groups, were also produced.

The most likely steps for this reaction are shown in Scheme I, eq. 3-10.

This reaction path involves multiple steps, which are consistent with the literature. However, it is oversimplified in that all the Grignard intermediates formed, such as shown in eq. 6 and 8, can react with any active Si-Cl available, not just starting material. It can be seen, according to Scheme I, that linear siliconmethylenes terminated by unreacted \equiv SiCH₂Cl and \equiv SiCl groups can also be produced in addition to cyclic compounds.

One can postulate that the reason for the success of the inverse addition process is that this procedure favors the production of $ClCH_2(CH_3)_2SiCH_2Si(CH_3)_2Cl$ according to eq. 4, since only small amounts of ClMg- $CH_2Si(CH_3)_2Cl$ will be formed in an environment rich in $ClCH_2Si(CH_3)_2Cl$. This advantage holds until the concentration of $ClCH_2(CH_3)_2SiCH_2Si(CH_3)_2Cl$ becomes appreciable. The normal addition method, in contrast, will produce a relatively high concentration of ClMg- $CH_2Si(CH_3)_2Cl$ resulting in a preponderance of chain lengthening reactions.

One of the major objects of this research was to produce cyclic siliconmethylenes having silicon functionality, *i.e.*, compounds containing Si-halogen, Si-H, and Si-alkoxy bonds. The direct preparation of 1,3dichloro-1,3-dimethyl-1,3-disilacyclobutane (IV), according to eq. 11, gave low yields as a result of the many side reactions which can occur as evidenced by the large yield of the isotropic mixture, $C_6H_{15}Cl_3Si_3$. This mixture could be separated into two components: a liquid, $Cl_2(CH_3)SiCH_2Si(CH_3)CH_2Si(CH_3)(Cl)CH_2$ (V),

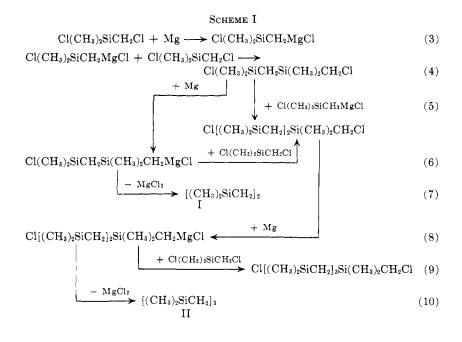
and a solid, $[Cl(CH_3)SiCH_2]_3$ (VI), the major portion being V. According to the reaction path proposed, the possible expected intermediate, $Cl_2(CH_3)SiCH_2Si(CH_3)$ - $(Cl)CH_2Si(CH_3)(Cl)CH_2MgCl$, could couple with itself

⁽¹⁾ University of Pennsylvania, Philadelphia, Pa.

⁽²⁾ R. K. Ingham and H. Gilman, "Inorganic Polymers," F. G. A. Stone and W. A. G. Graham, Ed., Academic Press, New York, N. Y., 1962, p. 321.
(3) W. H. Knoth, Jr. and R. V. Lindsey, Jr., J. Org. Chem., 23, 1392

⁽⁵⁾ G. Fritz and J. Grobe, Z. anorg. allgem. Chem., 315, 157 (1962);
G. Fritz, W. Kemmerling, G. Sonntag, H. J. Becker, E. H. V. Ebsworth, and J. Grobe, *ibid.*, 321, 10 (1963). The latter paper includes a correction of a previous work [G. Fritz and J. Grobe, *ibid.*, 311, 325 (1961)] in which the structure (CH3)₂Si=CHSi(CH₃) was assigned to Si₂CeH₃.

⁽⁶⁾ R. Müller, R. Köhne, and H. Beyer, Ber., 95, 3030 (1962).



 $2\text{ClCH}_{2}\text{Si}(\text{CH}_{3})\text{Cl}_{2} + 2\text{Mg} \xrightarrow{} [\text{Cl}(\text{CH}_{3})\text{Si}\text{CH}_{2}]_{2} + 2\text{MgCl}_{2} \quad (11)$

by interaction of the Grignard end with the silicon halogen bond in either the 4- or the 6-position leading to V or VI, respectively. An alternate course to V would be the reaction of the intermediate, $Cl_2(CH_3)SiCH_2Mg$ -Cl with IV. Proof of the structures IV, V, and VI is discussed later.

To eliminate the side reactions discussed above the starting silane was modified by substituting the less active ethoxy group for one of the chlorines on silicon, *i.e.*, $ClCH_2Si(CH_3)(OC_2H_5)Cl$. This resulted in a moderate (35.3%) yield of 1,3-diethoxy-1,3-dimethyl-1,3disilacyclobutane (VII), along with a small quantity of 1,3,5-triethoxy-1,3,5-trimethyl-1,3,5-trisilacyclohexane (VIII). When the starting silane had both active chlorines replaced by ethoxy groups, *i.e.*, ClCH₂Si(CH₃)- $(OC_2H_5)_2$, the reaction with magnesium gave 12.4% VII and a moderate (40.4%) yield of VIII. These results are consistent with the proposed scheme in that the intermediate $Cl(C_2H_5O)(CH_3)SiCH_2Si(CH_3)(OC_2H_5)CH_2$ -MgCl would be more likely to undergo a ring closure reaction than the intermediate of the second case, $(C_2$ - $H_5O_2(CH_3)SiCH_2Si(CH_3)(OC_2H_5)CH_2MgCl$, due to the steric hindrance of the ethoxy groups. The latter would more readily proceed similarly to eq. 5, resulting eventually in the formation of (C₂H₅O)₂(CH₃)SiCH₂- $Si(CH_3)(OC_2H_5)CH_2Si(CH_3)(OC_2H_5)CH_2MgCl$ which can undergo a less hindered ring closure reaction to give the six-membered ring, VIII.

Derivatives and Conversions.—Compounds I through XVI and some of their physical properties are summarized in Table I. The ethoxy derivatives VII and VIII were converted to the corresponding chloro derivatives IV and VI, respectively, by conventional means. The latter chloro derivatives gave high yields of the hydride derivatives IX and X with lithium aluminum hydride. Complete methylation of IV, VI, VII, and VIII with methyl Grignard gave the known methyl derivatives I and II. Partial methylation of IV and VII gave the monofunctional derivatives XI and XII, respectively. Compound V was methylated to give XIII. An alternate preparation of XIII was accomplished by the reaction of XI with $(CH_3)_3SiCH_2Li$. Compounds IV and VI were readily converted to phenyl derivatives using phenyl Grignard. The novel siloxane XVI resulted from the hydrolysis of XII.

Some of the derivatives (IV-X, XIV, and XV) of 1,3-disilacyclobutane and 1,3,5-trisilacyclohexane obviously can have isomeric forms. However, none as yet have been resolved into one form or the other and must be assumed to be mixtures.

Spectroscopic Data.-The infrared spectra of compounds I through XVI were recorded on a Perkin-Elmer Model 21 spectrophotometer equipped with sodium chloride optics. Their absorption frequencies are recorded in Table II. Assignments were made wherever possible. All compounds, except VI (which was dissolved in carbon tetrachloride), were examined as thin films between sodium chloride plates. Of particular interest in these spectra is the position of the Si-CH₂-Si band which in linear siliconmethylenes is found in the 1050-cm.⁻¹ region.⁷ This band is usually much narrower than the broad Si-O-Si absorption frequency also found around 1050 cm.⁻¹. The 1,3,5-trisilacyclohexane derivatives gave an absorption band in the 1040–1065cm.⁻¹ region, but the 1,3-disilacyclobutane derivatives absorbed between 935-955 cm.⁻¹. This shift may be attributed to the strained ring structure of the latter compounds and may be compared to the similar shifts of the Si-O-Si frequency which occur in several cyclic siloxanes as the ring size is decreased.^{8.9} In the compounds Cl₂(CH₃)SiCH₂Si(CH₃)CH₂Si(CH₃)(Cl)CH₂ and

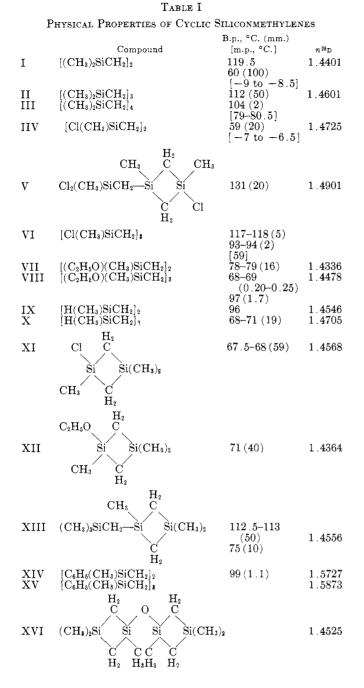
 $(CH_3)_3SiCH_2Si(CH_3)CH_2Si(CH_3)_2CH_2$ which contain

both a linear and cyclic Si–CH₂–Si structure, two bands are indeed found, one in the 1050-cm.⁻¹ region and one in the 950-cm.⁻¹ region.

(8) W. A. Piccoli, G. G. Haberland, and R. L. Merker, J. Am. Chem. Soc., 82, 1883 (1960).

⁽⁷⁾ H. Kriegsmann, Z. Electrochem., 61, 1088 (1957).

⁽⁹⁾ A. W. P. Jarvie, H. J. S. Winkler, and H. Gilman, J. Org. Chem., 27, 614 (1962).



Experimental

Materials.—Anhydrous ether was used without further treatment. Tetrahydrofuran was distilled as needed from lithium aluminum hydride. Magnesium turnings were ground to 2mm, mesh and stored under nitrogen. Grignard reagents were standardized commercial products unless otherwise indicated. Commercially available chloromethyldimethylchlorosilane and chloromethylmethyldichlorosilane were redistilled on a 36-in. spinning band column. Ethoxy derivatives of the latter were prepared as described below.

Chloromethylmethylethoxychlorosilane was prepared by the partial ethanolysis of $(CH_3)(CH_2Cl)SiCl_2$. To a vigorously stirred solution of 655.0 g. (4.005 moles) of $(CH_3)(CH_2Cl)SiCl_2$ and 316.4 g. (4.000 moles) of pyridine in 500 ml. of benzene was slowly added 184.2 g. (3.998 moles) of ethanol over a period of 4 hr. After an additional 16 hr. of stirring, the pyridine hydrochloride was filtered off and washed with benzene. The benzene was removed from the filtrate by distillation. Fractional distillation of the residue gave 435.7 g. (2.517 moles, 62.9% yield) of $(CH_3)(CH_2Cl)Si(OC_2H_5)Cl, b.p. 64^{\circ}$ (40 mm.), $n^{25}D$ 1.4256.

Anal. Calcd. for $C_4H_{10}Cl_2OSi$: C, 27.75; H, 5.82; Cl, 40.96; nol. wt., 173. Found: C, 28.07; H, 5.83; Cl, 41.13; mol. wt.,

175. All molecular weights were determined cryoscopically in benzene unless otherwise indicated.

Chloromethylmethyldiethoxysilane was prepared in a similar manner. $(CH_3)(CH_2Cl)SiCl_2$ (327 g., 2.00 moles) reacted with excess ethanol (240 ml., 4.09 moles) in the presence of pyridine (320 ml., 3.97 moles) in 300 ml. of benzene. Distillation yielded 239 g. (1.43 moles, 71.5% yield) of $(CH_3)(CH_2Cl)Si(OC_2H_5)_2$, b.p. 67° (20 mm.), lit.¹⁰ b.p. 162–165°, $n^{25}D$ 1.4120, lit.¹⁰ $n^{20}D$ 1.4145.

Reaction Procedure.—The reactions were carried out under nitrogen in conventional standard tapered glassware unless otherwise indicated. A conventional vacuum line was used for the manipulation of small quantities.

Reaction 1. Chloromethyldimethylchlorosilane and Magnesium. A. No Solvent.—No reaction occurred when 2.62 g. (0.0183 mole) of $(CH_3)_2(CH_2Cl)$ SiCl and 0.50 g. (0.021 g.-atom) of magnesium were heated to reflux in a sealed evacuated Carius tube.

B. In Diethyl Ether.—To a mixture of 6.1 g. (0.25 g.-atom)of magnesium in 100 ml. of ether, plus a few iodine crystals to activate the magnesium, was slowly added, over a period of 3.5 hr., a 50% solution of 35.5 g. (0.248 mole) of $(CH_3)_2(CH_2CI)SiCl$ in ether while heating to reflux. The reaction mixture became cloudy and upon an additional 16 hr. of stirring a thick white sludge was produced. The product was hydrolyzed, extracted with ether, and distilled to give 1.79 g. (0.0124 mole, 10.0% yield)of 1,1,3,3-tetramethyl-1,3-disilacyclobutane (I); mol. wt. found, 145 (vapor density), and calcd., 144; b.p. 119.5°, lit.³ b.p. 117-119°. A viscous yellow clear residue was the major product. C. In Tetrahydrofuran.—To a mixture of 20 g. (0.82 g.-atom)

of magnesium in 50 ml. of tetrahydrofuran was added a small amount of iodine and 4 drops of methyl iodide. To this stirred mixture was slowly added over a period of 2.5 hr., 71 g. (0.50 mole) of (CH₃)₂(CH₂Cl)SiCl in sufficient tetrahydrofuran to make a 33% solution. The exothermic reaction was cooled occasionally. After the reduction had subsided, the viscous slurry, due to the large amount of magnesium chloride formed, was heated to reflux for 2 hr. and then cooled. A slow addition of 250 ml. of water produced two layers which were separated. The water layer was extracted with ether and the extract was added to the organic layer and distilled to give 2.4 g. (0.017 mole, 6.7%yield) of I, b.p. 60° (100 mm.), identified also by infrared; 0.50 g. (0.0023 mole, 1.4% yield) of 1,1,3,3,5,5-hexamethyl-1,3,5-trisilacyclohexane (II), b.p. 120° (50 mm.); and 21 g. (58% yield based on $[(CH_3)_2SiCH_2]_n)$ of a viscous opaque residue, mol. wt. 930 ± 10 , the infrared spectrum of which indicated a siliconmethylene polymer.

D. Reverse Addition in Tetrahydrofuran.—To a small mixture of magnesium turnings covered by tetrahydrofuran was added 4 drops of methyl iodide followed by the addition of a small portion of 284 g. (1.98 moles) of $(CH_3)_2(CH_2Cl)SiCl$ to start the reaction which was evidenced by a sharp exotherm. The remainder of the silane, in sufficient tetrahydrofuran to bring the final silane concentration to 33%, was added rapidly with continuous stirring. The remainder of 80 g. (3.3 g.-atoms) of magnesium turnings was slowly added to maintain a reaction temperature of $30-50^{\circ}$ over a period of 2 hr. Occasional cooling was necessary. After an additional 1.5 hr. of stirring with heating to 50°, the reaction was cooled and 500 ml. of water was added slowly. The organic layer was separated, washed with water, and distilled to give 71.3 g. (0.494 mole, 49.9% yield) of I, m.p. -9 to -8.5° (by magnetic plunger technique¹¹), b.p. $60.5-61.0^{\circ}$ (100 mm.), n^{25} 1.4401, lit.³ n^{27} D.1.4380, d_{25} 0.793.

Anal. Calcd. for $C_6H_{16}Si_2$: C, 49.91; H, 11.17; mol. wt., 144. Found: C, 50.03; H, 11.37; mol. wt., 145 (vapor density).

In addition there was obtained 26.7 g. (0.123 mole, 18.6% yield) of II, b.p. 112° (50 mm.), lit.¹² b.p. 96-97° (26 mm.), n^{25} D 1.4601, lit.¹³ n^{25} D 1.4606.

Anal. Caled. for C₉H₂₄Si₃: C, 49.91; H, 11.17; mol. wt., 217. Found: C, 49.94; H, 11.00; mol. wt., 215.

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⁽¹⁰⁾ K. A. Andrianov and L. M. Volkova, Zh. Obshch. Khim., **30**, 2393 (1960).

⁽¹¹⁾ A. Stock, "Hydrides of Boron and Silicon," Cornell University Press, Ithaca, N. Y., 1933, p. 184.

⁽¹²⁾ N. S. Nametkin, A. V. Topchiev, and V. I. Zetkin, *Dokl. Akad. Nauk SSSR*, **93**, 1045 (1953).

	Assignments	C-H stretch (C ₆ H ₅ Si)	C-H streach (CH ₃ Si) and/or (C ₂ H ₅ —O—Si) Si-H stretch		CH ₂ deformation (C ₂ H ₅ OSi) CH ₂ deformation (C ₂ H ₅ OSi)	CH_a^{-C} detormation ($C_{e}H_a^{SD}$) $C=C$ stretch ($C_{e}H_a^{SD}$) CH_2 deformation (antisym.)	CH2 deformation (SiCH2Si)	C-H deformation (C ₆ H ₅ Si) C.H.OSi characteristic	CH3-Si sym. deformation	C ₂ H ₅ OSi rocking	C ₆ H ₅ –Si or o o o o o o o o o		VIII2 wag (DICHIELL) Si-O-Si	
LABLE 11 INFRARED ABSORPTION FREQUENCIES OF CYCLIC SILICONMETHYLENES ⁴		1000	2909 s 2910 ms			1403 m	1342 s		1252 vs				1050 vs	ev 6201
	XV			1955 w 1875 w 1810 w 1810 m	$1488\mathrm{m}$	1430 vs 1407 vw 1403 m	1355 m 1342 s	1298 w	1253 s	1190 w	1153 w 1108 vs		1006	м 966 84 с701
	XIV	3090 ms 3040 ms	2920 ms	1965 w 1885 w 1815 w 1765 w 1645 vw 1590 w	1490 ms 1488 m	1434 vs 1407 w	1345 m	1302 w	1251 vs	1190 w	1157 w 1115 vs	1090 w 1067 w		1010 m 1000 m 987 w
	ХШ		2900 s 2910 ms			$1405 \mathrm{m}$	1355 ms 1345 m		1250 vs				1040 VS	
	XII		29/08 2905 m 2735 vw		1482 w		1350 m	1900	1251 vs	$1165 \mathrm{m}$	1107 vs	1080 vs		
	IX		2970 ms 2910 m			1402 m	1350 s		1250 vs					
	x	0000	2900 s 2915 m 2120 vs			1415 w	1360 m		1252 vs				1040 V8	
	Compound		2975 ms 2920 w 2140 vs			1415 w	1357 m		1258 ms					
			2975 ms 2890 m 2750vw			1447 w 1395 m	1353 m	1905	1256 s	1165 ms 1166 ms	1110 vs		1040 vs	
	IIA		2985 s 2900 m		1485 w	1447 w 1393 m	1342 m	- 6061	1253 s	1165 ms	1105 vs	1075 vs		
	Λ^{Ip}		2970 m 2920 w			1405 m	1350 m		1258 s				1050 VS	
	Λ		3009 m 2970 w			1405 m 1415 ms	1352 s		1262 s				1065 vs	
	1V		2980 m 2920 w			1405 m	1345 s		1256 vs					
	III		$2970 \mathrm{ms}$ $2910 \mathrm{ms}$			1420 w	1398 w 1374 m		1255 vs			0	1048 vs	
	II		2960 m 2910 m			1410 w	1355 w		1250 vs 1184	M		1	1045 vs 1048 vs	
	-		2995 s 2930 m			1410 w	1365 m	1340 m	1255 vs					

TABLE II

		Ö	C ₂ H ₅ OSi characteristic		Si-H bending		Si-CH ₃ rocking, Si-C stretch, and Si-O stretch							Si-C ₆ H ₅		
975 в		938 vs	$910\mathrm{m}$				835 vs	801 vs	780 vs	758 s	$737 \mathrm{m}$	680 s				
				$906 \mathrm{m}$			810 vs	772 vs						730 vs	694 vs	nloride.
		939 vs				865 ms	818 vs	782 vs	767 s				640 m	728 vs	699 vs	on tetracl
		937 vs					835 (b)vs	vs 780 vs 785 vs 782 vs 77	757 s			685 s				In carbo
		940 vs	918s			860 vs	825 vs	780 vs			740 m	$692 \mathrm{s}$				peak). ⁴
		942 vs	925 s			860 vs	820 vs	783 vs		$732 \mathrm{m}$	708 s	682 s	640 m			trongest
		$942 \mathrm{m}$			890(b) vs	870 vs		795 vs	738 vs			693 ms				y, (b) = broad (relative to the strongest peak). ^{b} In carbon tetrachloride.
		950 vs			890(b) vs	870 vs	$810 \mathrm{s}$					715 s				= broad (rel
		945 s					323 vs	787 я	760 ms			690 m				ery, (b)
		945 vs					835 vs	790 s	760 s			690 m				ık, v = v
							830 vs									w = we8
		950 vs	925 s			865			$\cdot \left(\mathrm{b} ight) \mathrm{vg}$			700	665 m			= medium,
		955 vs	920 ms			863 vs	842 vs	800 vs	765 vs		710 ms	687 ms	650 ms			trong, m
							825 (b) vs	785 s	750 s		730 m	686 ms	671 ms			^{<i>a</i>} Values are in cm. ⁻¹ ; $s = strong$, $m = medium$, $w = weak$, $v = ver$.
	955 w					850 vs	815 vs	785 mw	738 s			$680\mathrm{m}$	662 w			s are in c
		940 vs				870 vs	825 vb					$690 \mathrm{s}$				^a Value

Also obtained was 2.0 g. (0.0066 mole, 1.3% yield) of 1,1,3,3,-5,5,7,7-octamethyl-1,3,5,7-tetrasilacyclooctane (III), m.p. 79-80.5°, lit.¹⁴ m.p. 80.5-81°, b.p. 104° (2 mm.).

Anal. Calcd. for $C_{12}H_{22}Si_4$: C, 49.91; H, 11.17; mol. wt., 289. Found: C, 49.86; H, 11.19; mol. wt., 287.

The last product obtained was 18.8 g. (0.260 mole, 13.1% yieldbased on $[(CH_3)_2SiCH_2]_n)$ of a viscous residue presumably containing higher cyclics and linear dimethylsilmethylene compounds. Molecular distillation of this residue gave four cuts having the molecular weights of 608, 803, 820, and 1460 ± 10 corresponding to *n* values in the above formula of 8.5, 11.1, 11.4, and 20.2.

Reaction 2. Chloromethylmethyldichlorosilane and Magnesium.—The procedure of reaction 1D was followed except for the work-up of product which was extracted from the slurry with hexane and distilled. To 305.9 g. (1.871 moles) of $(CH_3)(CH_2Cl)$ -SiCl₂ were added 80 g. (3.3 g.-atoms) of magnesium to give 22.8 g. (0.123 mole, 13.1% yield) of 1,3-dichloro-1,3-dimethyl-1,3disilacyclobutane (IV), m.p. -7 to -6.5° (by magnetic plunger technique¹¹), b.p. 59° (20 mm.), n^{25} D 1.4725.

Anal. Calcd. for $C_4H_{10}Cl_2Si_2$: C, 25.94; H, 5.44; Cl, 38.29; neut. equiv., 185. Found: C, 25.75; H, 5.44; Cl, 38.05; neut. equiv., 193.

In addition, there was obtained 63.6 g. (0.229 mole, 36.7% yield) of an isotropic mixture of formula $C_6H_{16}Cl_3Si_3$, b.p. 108–109° (5 mm.).

Anal. Calcd. for $C_6H_{15}Cl_3Si_3$: C, 25.94; H, 5.44; Cl, 38.29; neut. equiv., 278. Found: C, 26.05; H, 5.36; Cl, 37.50; neut. equiv., 281.

This product was further fractionated to give mostly a liquid, assigned the structure $Cl_2(CH_3)SiCH_2Si(CH_3)CH_2Si(CH_3)(Cl)CH_2$

(V), b.p. 131° (20 mm.), n^{25} D 1.4901; and a small quantity of a solid, 1,3,5-trichloro-1,3,5-trimethyl-1,3,5-trisilacyclohexane (VI), b.p. 117-118° (5 mm.).

A yellow brown residue probably containing higher molecular weight cyclic and linear compounds remained.

Reaction 3. Chloromethylmethylethoxychlorosilane and Magnesium.—Following the procedure of reaction 2, 66.7 g. (0.385 mole) of $(CH_3)(CH_2Cl)Si(OC_2H_5)Cl$ in sufficient tetrahydrofuran to bring the final silane concentration to 30% was treated with 15.0 g. (0.617 g.-atom) of magnesium to give on distillation 13.9 g. (0.0680 mole, 35.3% yield) of 1,3-diethoxy-1,3-dimethyl-1,3-disilacyclobutane (VII), b.p. 78-79° (16 mm.), $n^{28}D$ 1.4336, d_{28} 0.912.

Anal. Calcd. for $C_8H_{20}O_2Si_2$: C, 47.00; H, 9.86; mol. wt., 204. Found: C, 46.88; H, 9.69; mol. wt., 202.

In audition, there was obtained 2.1 g. (0.0069 mole, 5.3%)yield) of 1,3,5-triethoxy-1,3,5-trimethyl-1,3,5-trisilacyclohexane (VIII), b.p. 68-69° (0.20-0.25 mm.), $n^{25}D$ 1.4478; and 14.6 g. (0.143 mole, 37.1%) yield based on $[(CH_3)(C_2H_5O)SiCH_2]_n)$ of a viscous residue containing higher cyclic and linear methylethoxysilmethylene compounds.

Reaction 4. Chloromethylmethyldiethoxysilane and Magnesium.—The procedure of reaction 2 was utilized. A 236-g. sample (1.431 moles) of $(CH_3)(CH_2Cl)Si(OC_2H_5)_2$ was treated with 45 g. (1.9 g.-atom) of magnesium to give 16.5 g. (0.0807 mole, 11.3% yield) of VII, b.p. 70° (10 mm.), $n^{25}D$ 1.4328, confirmed by infrared spectrum; and 44.5 g. (0.145 mole, 30.4% yield) of VIII, b.p. 97° (1.7 mm.), $n^{25}D$ 1.4483.

Anal. Caled. for $C_{12}H_{30}O_3Si_3$: C, 46.88; H, 9.69; mol. wt., 307. Found: C, 47.26; H, 9.73; mol. wt., 304.

In addition there was obtained a viscous residue of higher molecular weight methylethoxysilmethylene compounds.

Reaction 5. 1,3-Diethoxy-1,3-dimethyl-1,3-disilacyclobutane and Benzoyl Chloride.—A 14.5-g. (0.0708 mole) sample of VII was treated with 20.5 g. (0.146 mole) of benzoyl chloride at 115° for 20 hr. in the presence of a trace of ferric chloride. A 76.9% yield (10.1 g., 0.0545 mole) of IV was obtained on distillation; b.p. 59° (20 mm.); n^{25} D 1.4725; mol. wt. found, 183, and caled., 185; confirmed by infrared.

Reaction 6. 1,3,5-Triethoxy-1,3,5-trimethyl-1,3,5-trisilacyclohexane and Phosphorus Trichloride.—A 17.6-g. (0.0574 mole)sample of VIII was treated with 23.7 g. (0.173 mole) of PCl₃ at reflux for 9 hr. with a noted rise in the temperature from 75° to 108°. Distillation gave 13.0 g. (0.0468 mole, 81.5% yield) of VI, m.p. 59°, b.p. 93–94° (2 mm.).

(14) G. Fritz and H. Burdt, Z. anorg. allgem. Chem., 314, 35 (1962).

Anal. Calcd. for C₆H₁₆Cl₃Si₈: C, 25.94; H, 5.44; Cl, 38.29; mol. wt., 278. Found: C, 26.02; H, 5.61; Cl, 38.13; mol. wt., 277.

Reaction 7. 1,3-Dichloro-1,3-dimethyl-1,3-disilacyclobutane and Lithium Aluminum Hydride.-To a stirred slurry of 1.20 g. (0.0316 mole) of lithium aluminum hydride in 50 ml. of diethylene glycol dimethyl ether was slowly added 10.19 g. (0.0550 mole) of IV over a period of 30 min. After stirring for an additional 30 min., the product was fractionated in the vacuum line by trap to trap distillation to give 6.11 g. (0.0525 mole, 95.5% yield) of 1,3dimethyl-1,3-disilacyclobutane (IX), b.p. 96°, n²⁶D 1.4546.

Anal. Calcd. for C4H12Si2: C, 41.30; H, 10.40; mol. wt., 116. Found: C, 41.20; H, 10.34; mol. wt., 114 (vapor density).

Reaction 8. 1,3,5-Trichloro-1,3,5-trimethyl-1,3,5-trisilacyclohexane and Lithium Aluminum Hydride.-Utilizing the procedure of reaction 7, 6.70 g. (0.0241 mole) of VI dissolved in 25 ml. of ether and 2.0 g. (0.053 mole) of lithium aluminum hydride in 25 ml. of ether were treated to give on distillation 3.26 g. (0.0187 mole, 77.6% yield) of 1,3,5-trimethyl-1,3,5-trisilacyclohexane (X), b.p. 68-71° (19 mm.), n²⁶D 1.4705.

Anal. Caled. for C₈H₁₈Si₃: C, 41.30; H, 10.40; mol. wt., 174. Found: C, 41.75; H, 10.32; mol. wt., 173.

Reaction 9. 1,3-Dichloro-1,3-dimethyl-1,3-disilacyclobutane and Methylmagnesium Iodide in Excess.-To 0.0347 mole of freshly prepared (CH₃)MgI in 25 ml. of diethyl ether was slowly added 3.15 g. (0.0170 mole) of IV over a period of 30 min. followed by an additional 30 min. of stirring. The product was filtered and distilled to give 2.08 g. (0.0144 mole, 84.7% yield) of I; mol. wt. found, 145 (vapor density), and calcd., 144; confirmed by infrared spectrum.

Reaction 10. 1,3-Diethoxy-1,3-dimethyl-1,3-disilacyclobutane and Methylmagnesium Bromide in Excess.-A 1.94-g. (0.00949 mole) sample of VII was added to a solution of 0.024 mole of (CH_3) MgBr in ether, heated to reflux for 6 hr., and stirred for 16 hr. The product was fractionated to give 1.17 g. (0.00810 mole, 85.4% yield) of I, confirmed by infrared spectrum.

1,3,5-Trichloro-1,3,5-trimethyl-1,3,5-trisila-Reaction 11. cyclohexane and Methylmagnesium Bromide in Excess.-A 3.91-g. (0.0141 mole) sample of VI was treated with 0.045 mole of $(CH_3)MgBr$ in the manner described in reaction 10. Fractionation gave 2.92 g. (0.0135 mole, 95.7% yield) of II, n^{25} D 1.4605, confirmed by infrared spectrum.

Reaction 12. 1,3-Dichloro-1,3-dimethyl-1,3-disilacyclobutane and Methylmagnesium Bromide in Equimolar Quantities .-- To an ether solution of 7.70 g. (0.0416 mole) of IV was slowly added 0.042 mole of (CH₃)MgBr over a period of 30 min. The reaction was stirred 16 hr., filtered, and distilled to give 0.20 g. of I and 3.40 g. (0.0206 mole, 49.5% yield) of 1-chloro-1,3,3-tri-methyl-1,3-disilacyclobutane (XI), b.p. 67.5-68° (59 mm.), n²⁵D 1.4568.

Anal. Calcd. for C₅H₁₃ClSi₂: C, 36.44; H, 7.95; Cl, 21.52. Found: C, 37.24; H, 8.21; Cl, 19.84.

Reaction 13. 1,3-Diethoxy-1,3-dimethyl-1,3-disilacyclobutane and Methylmagnesium Bromide in Equimolar Quantities.-A 15.9-g. (0.0778 mole) sample of VII and 0.078 mole of (CH₃)-

MgBr were treated as described in reaction 12. Distillation of the product gave 4.40 g. (0.0252 mole, 32.4% yield) of 1ethoxy-1,3,3-trimethyl-1,3-disilacyclobutane (XII), b.p. 71° (40 mm.), n²⁴D 1.4364.

Anal. Caled. for C7H18OSi2: C, 48.21; H, 10.40; mol. wt.,

174. Found: C, 48.31; H, 10.30; mol. wt., 175. Reaction 14. 1-Methyldichlorosiliconmethylene-3-chloro-1,3dimethyl-1,3-disilacyclobutane and Methylmagnesium Iodide. To 0.0555 mole of freshly prepared (CH₃)MgI was slowly added 5.00 g. (0.0180 mole) of V over a 30-min. period. The product was hydrolyzed, extracted with ether, and distilled to give 2.90 g. (0.0134 mole, 74.5% yield) of 1-trimethylsilmethyl-1,3,3-trimethyl-1,3-disilacyclobutane (XIII), b.p. 112.5-113° (50 mm.), n²⁵D 1.4578.

Reaction 15. 1-Chloro-1,3,3-trimethyl-1,3-disilacyclobutane and Trimethylsiliconmethylene Lithium.—A 4.50-g. (0.0273 mole) sample of XI was added to (CH₃)₃SiCH₂Li prepared from 5.49 g. (0.0447 mole) of $(CH_3)_3SiCH_2Cl$ and excess lithium dispersion (0.26 mole) in hexane. The reaction was heated to reflux for 40 hr., cooled and filtered, and fractionated in vacuo to give 4.20 g. (0.0194 mole, 71.0% yield) of XIII, b.p. 75° (10 mm.), n^{25} D 1.4556. The infrared spectrum was identical with XIII prepared in reaction 14.

Anal. Calcd. for C₉H₂₄Si₃: C, 49.91; H, 11.17; mol. wt., 217. Found: C, 51.64; H, 11.19; mol. wt., 219.

Reaction 16. 1,3-Dichloro-1,3-dimethyl-1,3-disilacyclobutane and Phenylmagnesium Bromide in Excess.-To a solution of 0.0699 mole of $(C_6H_5)MgBr$ in 35 ml. of ether was slowly added 5.93 g. (0.0320 mole) of IV over a period of 30 min. The reaction was refluxed for 6 hr., stirred for 16 hr. more, and hydrolyzed; and the product was extracted with ether. Upon evaporation of all high volatiles, 8.00 g. (0.0298 mole, 93.1% yield) of crude 1,3dimethyl-1,3-diphenyl-1,3-disilacyclobutane (XIV) was obtained. The product was difficult to distil conventionally and was best purified by molecular distillation. The physical properties were b.p. 99° (1.1 mm.), n²⁵D 1.5727.

Anal. Caled. for C16H20Si2: C, 71.57; H, 7.51; mol. wt., 269. Found: C, 71.89; H, 7.41; mol. wt., 263.

Reaction 17. 1,3,5-Trichloro-1,3,5-trimethyl-1,3,5-trisilacyclohexane and Phenylmagnesium Bromide in Excess.-Following the procedure of reaction 16, the interaction of 0.054 mole of $(C_6H_5)MgBr$ and 4.19 g. (0.0151 mole) of VI gave on work-up 4.01 g. (0.00996 mole, 66.0% yield) of crude 1,3,5-trimethyl-1,3,5-triphenyl-1,3,5-trisilacyclohexane (XV). Biphenyl which was formed as a by-product was sublimed in vacuo, and the residue was purified by molecular distillation. The purified XI was a slightly yellow viscous liquid, n^{25} D 1.5873.

Anal. Calcd. for C₂₄H₃₀Si₃: C, 71.57; H, 7.51; mol. wt., 403. Found: C, 69.85; H, 7.44; mol. wt., 402.

Reaction 18. Hydrolysis of 1-Ethoxy-1,3,3-trimethyl-1,3-disilacyclobutane.--A 8.10-g. (0.0464 mole) sample of XII was combined with 10.0 g. (0.555 mole) of water in 10 ml. of ethanol and refluxed for 16 hr. Ether extraction of the resulting mixture gave 5.20 g. (0.0189 mole, 81.8% yield) of bis(1,3,3-trimethyl-1,3-disilacyclobutyl)-1-siloxane (XVI), n²⁵D 1.4525.

Anal. Calcd. for C10H26OSi4: C, 43.73; H, 9.54; mol. wt., 275. Found: C, 43.49; H, 9.54; mol. wt., 272.